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# Charge neutral current generation in a spontaneous quantum Hall antiferromagnet

Miuko Tanaka<sup>1</sup>, Yuya Shimazaki<sup>2</sup>, Ivan Valerievich Borzenets<sup>3</sup>, Kenji Watanabe<sup>4</sup>, Takashi Taniguchi<sup>4</sup>, Seigo Tarucha<sup>5</sup>, and Michihisa Yamamoto<sup>5</sup>

<sup>1</sup>*Department of Applied Physics, University of Tokyo, Bunkyo-ku, Japan.* <sup>2</sup>*Institute of Quantum Electronics, ETH Zurich, Zurich, Switzerland.* <sup>3</sup>*Department of Physics, City University of Hong Kong, Hong Kong.* <sup>4</sup>*National Institute for Materials Science, Tsukuba-shi, Japan.* <sup>5</sup>*Center for Emergent Matter Science, RIKEN, Wako-shi, Japan*

Intrinsic Hall effect allows for generation of a non-dissipative charge neutral current, such as a pure spin current generated via the spin Hall effect. Breaking of the spatial inversion or time reversal symmetries, or the spin-orbit interaction is generally considered necessary for generation of such a charge neutral current. Here we challenge this general concept and present generation and detection of a charge neutral current in a centrosymmetric material with little spin-orbit interaction. We employ bilayer graphene, and find enhanced nonlocal transport in the quantum Hall antiferromagnetic state, where spontaneous symmetry breaking occurs due to the electronic correlation.

1 A charge neutral current such as a pure spin  
2 current is promising for future low-energy  
3 consumption devices because it does not  
4 accompany Joule heating [1,2]. While Hall  
5 effect allows for mutual conversion between a  
6 charge neutral current and an electric field  
7 [3], the role of the electronic correlation  
8 effect in this phenomenon has not yet been well  
9 understood. 39  
10 Electron correlated systems are generally  
11 sensitive to external perturbations and  
12 undergo various phase transitions under the  
13 change of control parameters. The correlation  
14 effect becomes important when the interaction  
15 energy is dominant over the kinetic energy,  
16 such as in the case of a flat band. An electron  
17 correlated system is achieved in a  
18 two-dimensional electron system by application  
19 of a perpendicular magnetic field, when the  
20 kinetic energy is quenched in Landau levels.  
21 For the existence of additional degree of  
22 freedoms (DOF) of electrons, such as the spin,  
23 layer, and valley, the electronic interaction  
24 leads to splitting of Landau levels to gain the  
25 exchange energy [4, 5]. Such splitting of Landau  
26 levels and emergence of an ordered phase takes  
27 place in the quantum Hall states of monolayer  
28 and bilayer graphene. 58  
29 Due to their zero-gap feature, monolayer and  
30 bilayer graphene have a Landau level at zero

energy, called as zero-th Landau level.  
Emergence of a gapped  $\nu=0$  state ( $\nu$  is the  
filling factor) due to the splitting of zero-th  
Landau level has been experimentally observed  
both in monolayer and bilayer graphene [6-22].  
There has been a long theoretical debate on the  
nature of  $\nu=0$  state [23-36]. According to the  
recent coincidence between a theory [23] and a  
transport experiment under a tilted magnetic  
field [14], the most-likely state of bilayer  
graphene at low temperature is a canted layer  
antiferromagnet (CAF), where spins tend to  
align ferromagnetically due to the exchange  
interaction within each layer but  
anti-ferromagnetically between the layers  
(Fig. 1a). The CAF state has two unique features,  
which are distinct from those of conventional  
quantum Hall magnets in semiconductor-based  
two-dimensional electron systems. First,  
non-zero spin and valley contrasting Hall  
conductivity is theoretically expected [36,  
23], although it is experimentally elusive.  
Second, absence of edge channels was reported  
experimentally [10-18], and theoretically  
explained by valley scattering at sample edges  
[23,24], in spite of the expected Hall  
conductivity.

Owing to these two unique properties, the CAF  
state in bilayer graphene is a suitable system  
to study a new way of charge neutral current

1 generation. When a charge current is injected, 59  
2 a “spin-valley current”, which we define as 60  
3 the difference of valley current between the 61  
4 spins, flows perpendicularly to the injected 62  
5 current (Fig. 1b) owing to the spin and valley 63  
6 contrasting Hall conductivity. Because there 64  
7 is no edge channel, a non-dissipative 65  
8 spin-valley current flows through the bulk 66  
9 region. We call this phenomenon the 67  
10 “spin-valley Hall effect”. Existence of the 68  
11 spin-valley current seems to have been 69  
12 overlooked because it carries neither spin nor 70  
13 valley degree of freedom. 71

14 The spin-valley Hall effect is 72  
15 phenomenologically similar to the spin Hall 73  
16 effect [3] and valley Hall effect [37, 38, 74  
17 44-46], both of which have been extensively 75  
18 studied. However, the spin-valley current is 76  
19 very different from other charge neutral 77  
20 currents reported in previous researches in 78  
21 terms of symmetry and electron correlation. 79  
22 Generally, to realize non-zero Hall 80  
23 conductivity for each spin or valley, either 81  
24 the spin-orbit interaction or the breaking of 82  
25 spatial inversion or time reversal symmetries 83  
26 is necessary. In previous experimental studies, 84  
27 enhanced spin-orbit interaction by adatom 85  
28 doping or substrates effect were used in 86  
29 materials with weak spin-orbit interaction 87  
30 [39-43], and symmetries were broken by one-body 88  
31 effects such as non-centrosymmetric crystal 89  
32 structures [44-46] and application of an 90  
33 external electric field [37, 38]. In the CAF 91  
34 state, the spatial inversion and time reversal 92  
35 symmetries are broken spontaneously due to the 93  
36 electronic interaction [36, 23]. Because this 94  
37 interaction effect is sensitive to the filling 95  
38 factor and out-of-plane electric field, charge 96  
39 neutral current generation in the CAF state is 97  
40 gate tunable. 98

41 Another important distinction of the 99  
42 spin-valley Hall effect in terms of application 100  
43 is that it allows for coupling of the spin and 101  
44 valley DOFs. Because the Hall conductivity is 102  
45 spin and valley contrasting, if we inject an 103  
46 opposite current for each spin, or a spin 104  
47 current, a valley current is expected to flow 105  
48 in the transverse direction (Fig. 1c). While the 106  
49 spin-orbit interaction is weak in graphene, 107  
50 this mutual conversion between the spin current 108  
51 and valley current may open up a new possibility 109  
52 of electrical generation and detection of a 110  
53 spin current in graphene with high efficiency. 111

54 We fabricate Hall bars of bilayer graphene 112  
55 encapsulated in hexagonal boron nitride (h-BN) 113  
56 (Fig. 1d, e) by mechanical exfoliation, dry 114  
57 transfer, and side contact methods [47]. By 115  
58 applying voltages to the graphite (Hall bar 1) 116

or p-doped Si (Hall bar 2) back gate and gold  
top gate, the carrier density  $n$  and  
out-of-plane electric field (displacement  
field)  $D$  are tuned independently.

We study generation and detection of the  
charge neutral spin-valley current in the CAF  
state of bilayer graphene using nonlocal  
transport measurement. Nonlocal transport  
measurement is a well-established technique to  
study the spin Hall effect and valley Hall  
effect [3, 37, 38, 46, 50]. When a charge  
current is injected between the terminals 2 and  
6 of Fig. 1e, a charge neutral current is  
generated. Because of the non-dissipative  
nature of the charge neutral current, it can  
flow in the longitudinal direction of the Hall  
bar over distances of few microns. Voltage is  
then induced between the terminals 3 and 5,  
owing to the inverse Hall effect. The nonlocal  
resistance  $R_{NL}$  is defined as the ratio of the  
injected current to the detected nonlocal  
voltage  $V_{3-5}/I_{2-6}$ .

Previously, a large nonlocal resistance under  
an application of perpendicular magnetic field  
was reported for monolayer graphene [50]. It  
was interpreted as “Zeeman spin Hall effect”,  
where a spin current is generated due to Zeeman  
splitting at the charge neutral point (CNP).  
While the spin splitting ground state has been  
denied by recent understanding of the CAF state,  
their scenario is common with our proposal of  
the spin-valley Hall effect in a sense that the  
nonlocal resistance originates from a charge  
neutral current. However, previous study [50]  
had no experimental evidence of the charge  
neutral current generation as an origin of the  
nonlocal resistance. In our study, we observe  
characteristic scaling behavior of the  
nonlocal transport varying the magnetic field  
and temperature, which evidences the charge  
neutral current generation. In addition, based  
on recent understanding of the phase diagram of  
 $\nu=0$  state, we identify the spin-valley Hall  
effect by significant enhancement of the  
nonlocal resistance at the CAF state in  
dual-gated bilayer graphene.

In addition, to eliminate the possibility of  
edge transport as another origin of the large  
nonlocal resistance, we employ two Hall bars  
(Hall bars 1 and 2) with the same dimension of  
the active area but with different edge length  
by adding extra protruding part between the  
terminals 2 and 3 in one of the Hall bars (Hall  
bar 1) (Fig. 1d). We confirm that the value of  
nonlocal resistance is comparable, implying  
that the edge transport is not the origin of the  
enhanced nonlocal resistance and that the  
charge neutral current flows in the bulk, as we

1 see in the following. 59

2 We first measured the local resistance  $R_L$  60  
3  $=V_{2-3}/I_{1-4}$  at temperature  $T=1.7$  K in the linear 61  
4 transport regime ( $I_{1-4} < 5$  nA) to identify the 62  
5 CAF state. Figs. 2a-c are dual gate dependence 63  
6 of  $R_L$  obtained with Hall bar 2 (Fig. 1d) shown 64  
7 as a function of carrier density  $n$  and 65  
8 displacement field  $D$  obtained for various 66  
9 perpendicular magnetic fields. At zero 67  
10 magnetic field,  $R_L$  at the CNP monotonically 68  
11 increases with the displacement field  $D$  due to 69  
12 the opening of the single particle band gap. 69  
13 When the magnetic field of 2 T is applied, a 70  
14 local maximum appears around the  $D=0$  and  $n=0$  70  
15 indicating development of the CAF insulating 71  
16 state (Fig. 2d) [14, 19, 22]. This state becomes 71  
17 more robust with increasing magnetic field due 72  
18 to the reduced kinetic energy. When the 72  
19 displacement field is increased from zero,  $R_L$  72  
20 at the CNP once decreases and again increases. 72  
21 This upturn is attributed to closing of the CAF 73  
22 gap and phase transition to another insulating 73  
23 state, layer polarized (LP) state as reported 74  
24 in previous studies [14, 19, 22]. 75

25 We then performed nonlocal transport 75  
26 measurement for the CAF state. Figs. 2e and 2f 76  
27 show the  $n$  and  $D$  dependence of  $R_{NL}$  under the 77  
28 magnetic field of 2 T and 4 T, respectively. 77  
29 Similarly to  $R_L$ ,  $R_{NL}$  becomes maximal at  $D = 0$  78  
30 and  $n = 0$ . The peak value of  $R_{NL}$  is  $10^4$  times 79  
31 larger than that expected for the trivial 80  
32 classical current diffusion obtained from  $R_L$  80  
33 and van der Pauw formula [51].  $R_{NL}$  is suppressed 81  
34 at the phase boundary between the CAF and LP 82  
35 states, and has the same order of magnitudes in 82  
36 these two insulating states (Fig. 2e, Fig. S9). 83  
37 This indicates the same order of generation 83  
38 efficiency and decay of the charge neutral 84  
39 current, which is reasonable because both 84  
40 charge neutral currents are expected to be 85  
41 scattered only by atomically sharp defects or 85  
42 at sample edges [37, 38]. 86

43 Figs. 2g and 2h show the carrier density 86  
44 dependence of  $R_L$  and  $R_{NL}$  at  $D = 0$  under the 87  
45 magnetic field of 0 to 8 T. The peak of  $R_{NL}$  is 88  
46 sharper than that of  $R_L$  implying a nonlinear 88  
47 relationship between  $R_L$  and  $R_{NL}$  as discussed in 89  
48 the following [57]. Similar results were also 90  
49 obtained for the Hall bar 1 [58]. 90

50 We now turn to the relationship between  $R_L$  and 91  
51  $R_{NL}$ . We measure  $R_L$  and  $R_{NL}$  for  $D=0$  while sweeping 92  
52 the temperature from 1.7 to 32 K with the 92  
53 magnetic field as a parameter. The temperature 93  
54 in this range is less than the energy gap of the 94  
55 CAF state estimated from the boundary 94  
56 displacement field between the CAF state and 95  
57 the LP state, which is proportional to the 96  
58 magnetic field:  $\Delta_{CAF}/B \sim 40$  K/T [21, 59]. We 97

then plot the peak values of  $R_{NL}$  vs  $R_L$  (at  $n \sim 0$ ,  
see Figs. 2g and 2h) in Fig. 3. We find that all  
data points obtained with Hall bar 1 fall on a  
single curve of the cubic scaling for  $20 \text{ k}\Omega < R_L < 80 \text{ k}\Omega$ .  
In Hall bar 2, we observe linear  
scaling for  $R_L$  exceeding  $90 \text{ k}\Omega$ . Below  $R_L \sim 90 \text{ k}\Omega$ ,  
the scaling exponent becomes larger and  
becomes cubic below  $R_L \sim 30 \text{ k}\Omega$ .

Similarly to the spin Hall effect and valley  
Hall effect [3, 37, 38, 46],  $R_{NL}$  arising from the  
spin-valley Hall effect and inverse  
spin-valley Hall effect is given by the  
established formula,

$$R_{NL} = \frac{W}{2l} \frac{\sigma_H^2}{\sigma_{xx}(\sigma_{xx}^2 + \sigma_H^2)} e^{-L/l} \quad (1)$$

for a homogeneous semiclassical system. Here  
 $\sigma_{xx}$  is the local electrical conductivity,  $\sigma_H$   
is the spin-valley Hall conductivity defined as  
the driven spin-valley current density divided  
by the transverse in-plane electric field,  $W$   
is the Hall bar width,  $L$  is the Hall bar length,  
and  $l$  is the scattering length of the  
spin-valley current. Assuming the intrinsic  
mechanism of the Hall conductivity,  $\sigma_H$  is  
constant.  $R_L$  and  $R_{NL}$  should then have the cubic  
scaling relationship  $R_{NL} \propto \rho^3$  for  $\sigma_{xx} \gg \sigma_H$   
and linear scaling relationship  $R_{NL} \propto \rho$

for  $\sigma_{xx} \ll \sigma_H$ . This intrinsic scenario can  
account for our experimental result. Obtained  
scaling relationship is the evidence of  
nonlocal transport mediated by a charge neutral  
current generated by the intrinsic Hall effect.  
The absolute value of  $R_{NL}$  is also in a reasonable  
range for the theoretical value of  $\sigma_H = 4e^2/h$   
in Eq. 1 and comparable with the value obtained  
in previous studies on the nonlocal transport  
of valley Hall effect in bilayer graphene [37,  
38, 60].

Equation (1) indicates that scaling crossover  
from cubic to linear occurs around  $\rho =$

1  $h/4e^2 \sim 6.45 \text{ k}\Omega$ . However, Hall bar 1 exhibits  
 2 cubic scaling in all data up to  $\rho \sim 23 \text{ k}\Omega$  and  
 3 Hall bar 2 exhibits cubic scaling up to  
 4  $\rho \sim 17 \text{ k}\Omega$ . Unexpected cubic scaling for the  
 5 large  $\rho$  was also observed in previous  
 6 experiments on the valley Hall effect in a  
 7 bilayer graphene [38, 60]. Although the reason  
 8 for this contradiction is not yet understood,  
 9 one possibility is that the charge conductivity  
 10  $\sigma_{xx}$  in Eq. (1) may not simply be measured by the  
 11 electrical current divided by the in-plane  
 12 electric field, but be defined as effective  
 13 conductivity for the thermally activated  
 14 carriers [37]. Another possibility is that the  
 15 spin-valley Hall conductivity is reduced due to  
 16 sample dependent inhomogeneity.  
 17 To summarize our experimental findings, we  
 18 observe significant enhancement of the  
 19 nonlocal resistance at the CAF state, and cubic  
 20 and linear scaling relationship between the  
 21 local and nonlocal resistance. The observed  
 22 scaling is consistent with the theoretical  
 23 expectation of the spin-valley Hall effect and  
 24 implies that the origin of the enhanced  
 25 nonlocal resistance is the generation of a  
 26 charge neutral current by the intrinsic Hall  
 27 effect.  
 28 To further make sure this scenario, we here  
 29 discuss four other possible contributions to  
 30 the nonlocal resistance to show that their  
 31 contribution is minor.  
 32 First, current leakage through voltage  
 33 measurement terminals makes additional  
 34 contribution to the nonlocal resistance when  
 35 the input impedance of voltage amplifiers is  
 36 not high enough [37, 38]. However, this  
 37 contribution is confirmed to be small enough by  
 38 estimation and control measurement in  
 39 different voltage amplifiers [51].  
 40 Second, AC measurement can cause artifact of  
 41 nonlocal resistance due to the finite  
 42 capacitance between measurement lines and  
 43 ground. However, this contribution is  
 44 negligible since the measured nonlocal  
 45 resistances in lock-in measurement are  
 46 identical for two different reference  
 47 frequencies [51].  
 48 Third, thermal flow can also cause nonlocal  
 49 resistance due to the Ettingshausen and Nernst  
 50 effect [61]. The value of nonlocal resistance  
 51 due to the thermal effect estimated based on  
 52 previous researches on thermal properties of  
 53 graphene is too small to account for the  
 54 measured large  $R_{NL}$  at least above  $B=4 \text{ T}$  [51],  
 55 where we observe cubic and linear scaling  
 56 between  $R_L$  and  $R_{NL}$ . In a lower magnetic field  
 57 less than  $2 \text{ T}$ , the thermal effect may become  
 58 dominant. This might be responsible for the

deviation of the scaling relationship from the  
 expected one for the low magnetic field in Fig.  
 3.

Finally, another possible origin of nonlocal  
 resistance is current flow along the sample  
 edge. Although established both experimentally  
 [10-18] and theoretically [23, 24] that the CAF  
 state does not have an edge channel, gate  
 inhomogeneity at the sample edge can cause  
 carrier doping and produce less-resistive  
 regions along the edge. As already mentioned,  
 we have prepared Hall bars with different edge  
 lengths but with the same dimension of the  
 active area (Fig. 1d). Hall bar 1 has a 10 times  
 longer edge between the terminals 2 and 3  
 compared to that of Hall bar 2. Suppose carrier  
 transport occurs only at the edges,  $R_{NL}$  defined  
 as the ratio of the injected current to the  
 detected nonlocal voltage ( $V_{3-5}/I_{2-6}$  in Fig. 1d,  
 e) should be 10 times smaller for the long-edge  
 Hall bar (Hall bar 1). As shown in Fig. 3,  
 however, the values of nonlocal resistance are  
 comparable for the two Hall bars. This result  
 cannot be assigned to the edge contribution but  
 is consistent with the charge neutral current  
 in the bulk as the main contribution. In  
 addition, we measured comparable values of  
 nonlocal resistance for two other Hall bars  
 with different edge lengths (Fig. S4).

Thus all other possible contributions to the  
 nonlocal resistance are minor and the majority  
 of the signal is assigned to the generation of  
 a bulk charge neutral current by the intrinsic  
 Hall conductivity in the CAF state.

In this work, we have not directly identified  
 the Hall effect for each spin and valley.  
 Demonstration of the conversion between the  
 valley current and spin current at the CAF state  
 should directly evidence that the intrinsic  
 Hall conductivity is spin and valley  
 contrasting.

Since the valley Hall angle defined as the  
 induced valley current divided by the driving  
 electrical current in the valley Hall effect is  
 higher than the spin Hall angle of most of the  
 materials currently available in spintronics,  
 the spin-valley Hall effect may allow for  
 generation of a spin current at high efficiency  
 when combined with the valley Hall effect. We  
 also note that application of a perpendicular  
 magnetic field may not be necessary in future.  
 Using a flatter band available for example in  
 ABC-stacked several layers graphene, the CAF  
 (or AF) gap can exceed room temperature at zero  
 external magnetic field [6-9, 11, 13]. Our work  
 thus demonstrated a promising principle to  
 generate a charge neutral current in electron

1 correlated states. 12  
2 13  
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24  
25

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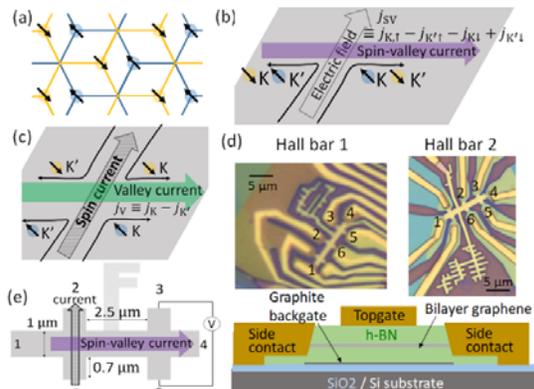


Fig. 1. Spin-valley Hall effect in the CAF state and device structure.

(a) Spin and sublattice configuration of the CAF state in bilayer graphene. Blue (yellow) hexagons are the lattices of the top (bottom) layer. Spins shown as arrows tend to align in each layer but

become opposite between the layers. (b) Schematic description of the spin-valley Hall effect and definition of the spin-valley current. Blue (yellow) circles indicate electrons on the top (bottom) layer, and arrows indicate spin. Spin-valley current is defined as  $I_{SV} = I_K - I_{\uparrow}$ , where  $I_K$  is the current of carriers belonging to the valley K and spin up. (c) Schematic description of the spin current to valley current conversion. The spin current (opposite charge current between the layers) generates the valley current in its transverse direction. (d) Optical microscope images of the two devices used for the experiments (upper panels). The two Hall bars have the same dimension as shown in Fig. 1e. One side of the Hall bar 1 has a jagged region sticking out of the Hall bar between the terminals 2 and 3 to examine the contribution of edge transport to the nonlocal resistance. The lower panel shows the schematic cross section of the device. The bilayer graphene is encapsulated by hexagonal boron nitride with thickness of 35~45 nm, and sandwiched between the top gate and graphite back gate. Hall bar 2 doesn't have graphite back gate and p-doped Si substrate is used as a back gate. (e) Schematic description of the nonlocal transport experiment. A charge current is injected between the terminals 2 and 6, and the nonlocal transport mediated by the spin-valley current is measured as the voltage induced between the terminals 3 and 5.

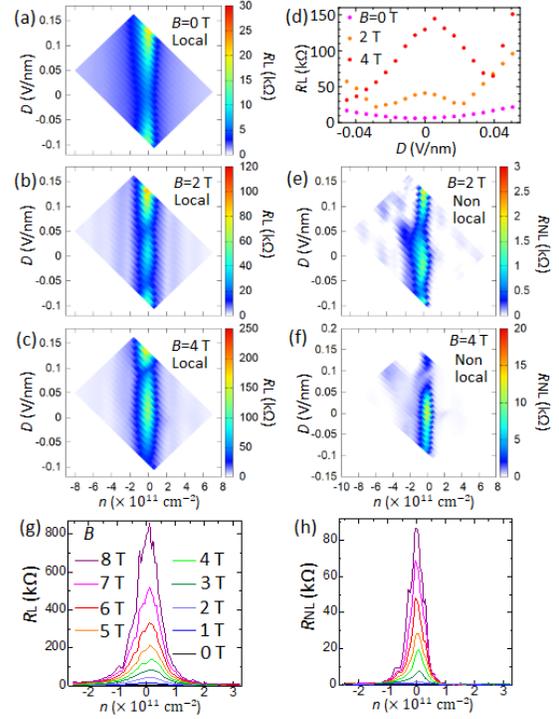


Fig. 2. Carrier density  $n$  and displacement field  $D$  dependence of the local resistance  $R_L$  and nonlocal resistance  $R_{NL}$  measured at  $n = 0$  for Hall bar 2.

(a), (b), (c)  $n$  and  $D$  dependence of  $R_L$  measured at the magnetic field of 0 T (a), 2 T (b), and 4 T (c), respectively.  $n$  and  $D$  are calculated from the top gate and back gate voltages using the literature value of dielectric constants of h-BN and SiO<sub>2</sub> and measured thickness of h-BN (see supplementary information 3). (d)  $R_L$  along the  $n=0$  lines in (a), (b), and (c), showing  $D$  dependence for the magnetic fields of 0, 2, and 4 T. (e), (f)  $n$  and  $D$  dependence of  $R_{NL}$  for 2 T (e), and 4 T (f), respectively. (g), (h)  $R_L$  dependence of  $R_L$  (g) and  $R_{NL}$  (h) along the  $n=0$  line, measured at the magnetic field of 0 to 8 T.

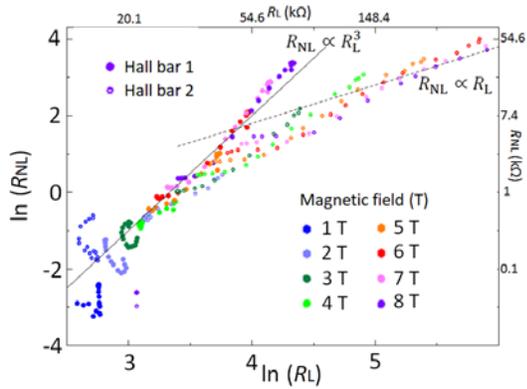


Fig. 3. Scaling relationship between  $\ln(R_{NL})$  and  $\ln(R_L)$ .

Peak values of  $R_{NL}$  along the  $R_{NL} \propto R_L^3$  line plotted as a function of that of  $R_L$  obtained in the range of temperature of 1.7 to 32 K and magnetic field of 1 to 8 T. The data points of the same color are taken at the same magnetic field. Dots and open circles denote the data from Hall bar 1 and Hall bar 2, respectively.

The solid (broken) line corresponds to the cubic (linear) scaling.

2817+530+(116+198+120)